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**REPLY UNDER 37 CFR 1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER 2800**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of: Divakaruni et al.	Conf. No.: 1387
Serial No.: 10/707,388	Art Unit: 2891
Filed: 12/10/2003	Examiner: Fulk, Steven J.
Title: SILICIDE RESISTOR IN BEOL LAYER OF SEMICONDUCTOR DEVICE AND METHOD	Docket No.: FIS920030274 (IBMF-0032)

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AFTER-FINAL REQUEST FOR RECONSIDERATION

Sir:

I. INTRODUCTORY COMMENTS:

In response to the Final Office Action of December 07, 2006, please reconsider the above-referenced patent application in view of the following remarks: